

IN THE UNITED STATES PATENT & TRADEMARK OFFICE

IN RE APPLICATION OF :
SHIGETSUGU HAYASHI ET AL : ATTN: APPLICATION DIVISION
SERIAL NO: NEW APPLICATION :
FILED: HEREWITH :
FOR: REPAIR AND REINFORCEMENT METHOD
FOR PREEXISTING STRUCTURES AND AN
ANISOTROPIC TEXTILE USED THEREFOR

PRELIMINARY AMENDMENT

ASSISTANT COMMISSIONER FOR PATENTS
WASHINGTON, D.C. 20231

SIR:

Prior to examination on the merits, please amend the above-identified application as follows:

IN THE SPECIFICATION

Page 2, line 13, delete the comma “,”;

delete lines 14-16 and insert --and this leads to a--.

Page 6, lines 9-10, delete”, or rainy conditions”;

line 24, delete “25” and insert --20--;

line 26, delete “capable of sufficient” and insert --curable--;

delete the last line in favor of: --in a period of time of 6--.

Page 7, line 1, delete “)” and insert --less--.

Page 8, line 14, delete "25" and insert --20--.

Page 48, lines 1 and 18, after "temperature" insert --(20°C)--.

Page 49, line 13, after "temperature" insert --(20°C)--.

Page 86, line 16, delete "25" and insert --20--.

IN THE CLAIMS

Please cancel Claims 1-14, 17 and 18.

DISCUSSION OF THE AMENDMENTS

The specification has been amended as in the parent application. All the claims have been cancelled except Claims 15, 16 and 19, drawn to a non-elected invention in the parent application.

REMARKS

The application is ripe for examination on the merits. An early examination is respectfully solicited.

Respectfully submitted,

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